

## Electronic Patent Application Fee Transmittal

<b>Application Number:</b>	10720735			
<b>Filing Date:</b>	24-Nov-2003			
<b>Title of Invention:</b>	REWORK PROCESS OF PATTERNED PHOTO-RESIST LAYER			
<b>First Named Inventor:</b>	Yu-Lin Yen			
<b>Filer:</b>	Daniel R. McClure/Hui Chin Barnhill			
<b>Attorney Docket Number:</b>	251310-1100			
Filed as Large Entity				
<b>Utility      Filing Fees</b>				
Description	Fee Code	Quantity	Amount	Sub-Total in USD(\$)
<b>Basic Filing:</b>				
<b>Pages:</b>				
<b>Claims:</b>				
<b>Miscellaneous-Filing:</b>				
<b>Petition:</b>				
<b>Patent-Appeals-and-Interference:</b>				
<b>Post-Allowance-and-Post-Issuance:</b>				
Utility Appt Issue fee	1501	1	1400	1400
Publ. Fee- early, voluntary, or normal	1504	1	300	300

Description	Fee Code	Quantity	Amount	Sub-Total in USD(\$)
Extension-of-Time:				
Miscellaneous:				
Total in USD (\$)				1700